INFORMATION DISCLOSURE CITATION

(Use several sheets if necessary)

Docket	Number	(Opti	a a	1)	
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WLJ.078

Application Number

10/018,809

Applicant(s)

Anand SRINIVASAN

Filing Date

12/21/2001

Group Art Unit

TO BELLENED

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*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	€	THE DES	FEAR ROPLAN
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EXAMINER

DATE CONSIDERED 3-04/

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Form PTO-A820 (also form PTO-1449) P09A/REV04

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